

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

PRELIMINARY AMENDMENT ACCOMPANYING APPLICATION

APPLICANT: Karou Koike, et al. ATTY. DOCKET NO. 09792909-5344

SERIAL NO.

DATE FILED:

INVENTION: "MASK-MAKING MEMBER AND ITS PRODUCTION METHOD,
MASK AND ITS MAKING METHOD, EXPOSURE PROCESS, AND
FABRICATION METHOD OF SEMICONDUCTOR DEVICE"

Assistant Commissioner of Patents

Washington, D.C. 20231

SIR:

Between the title and the heading "Background of the Invention" on page 1, insert the following:

--RELATED APPLICATION DATA

The present application claims priority to Japanese Application(s) No(s). P2001-046363 filed February 22, 2001, which application(s) is/are incorporated herein by reference to the extent permitted by law.--

Respectfully submitted,



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